

*Supporting Information for:*

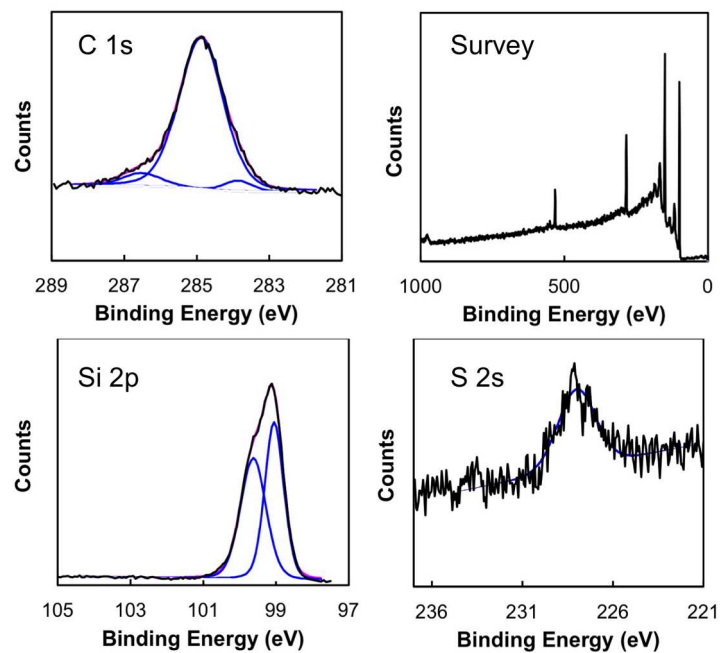
## **Heck Coupling of Olefins to Mixed Methyl/Thienyl Monolayers on Si(111) Surfaces**

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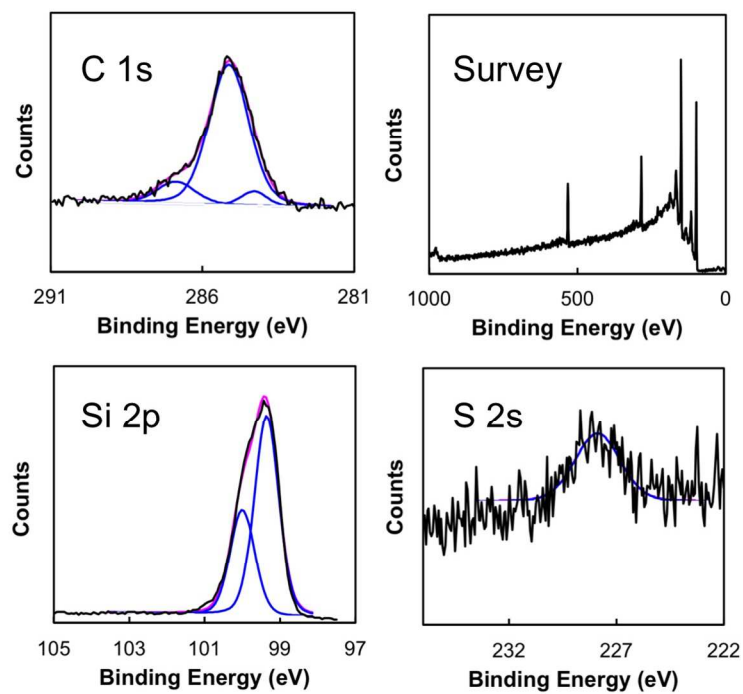
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## A. XP spectra

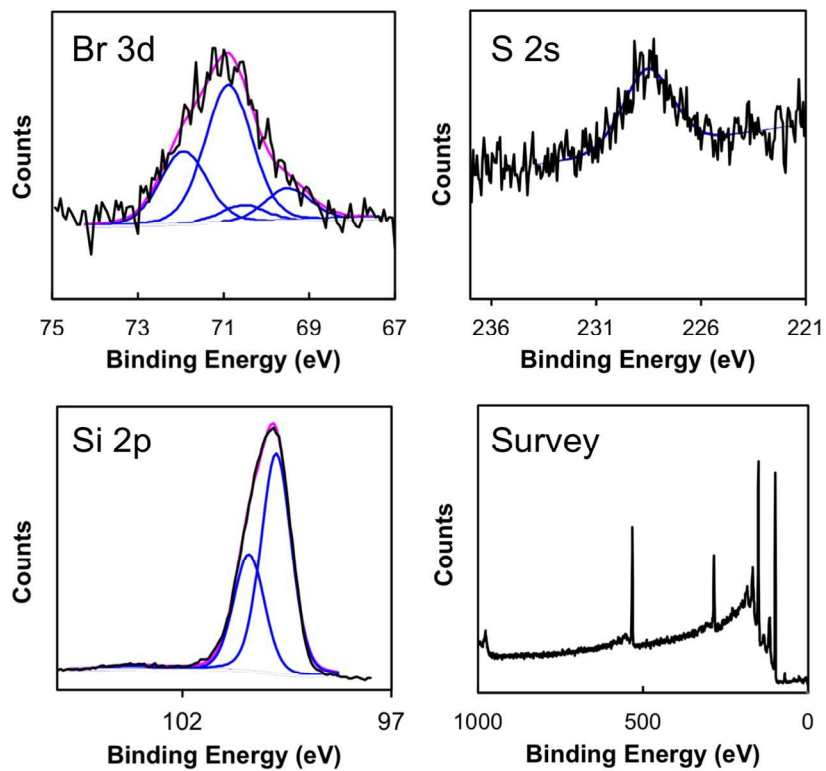


**Figure SA1.** C 1s (100 scans), Si 2p (40 scans), S 2s (200 scans), and survey (4 scans)

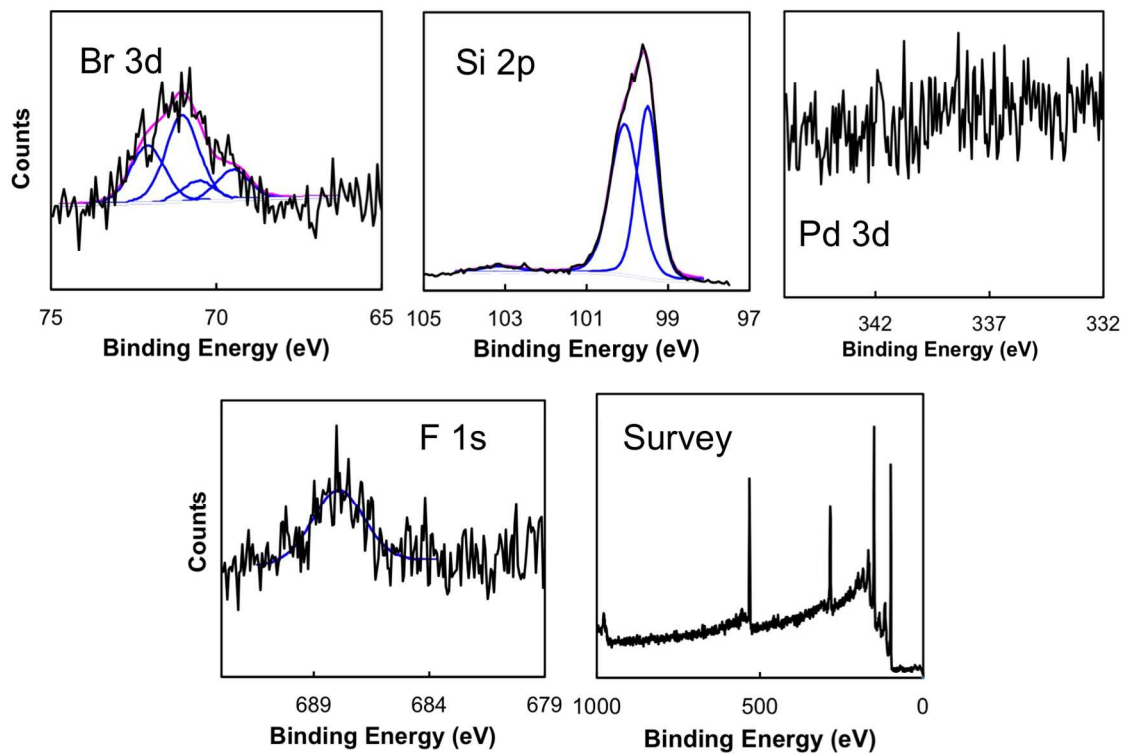
XP spectra of a mixed  $\text{CH}_3/\text{SC}_4\text{H}_9\text{-Si}(111)$  with  $\theta_{\text{SC}_4\text{H}_9} \approx 0.20$ .



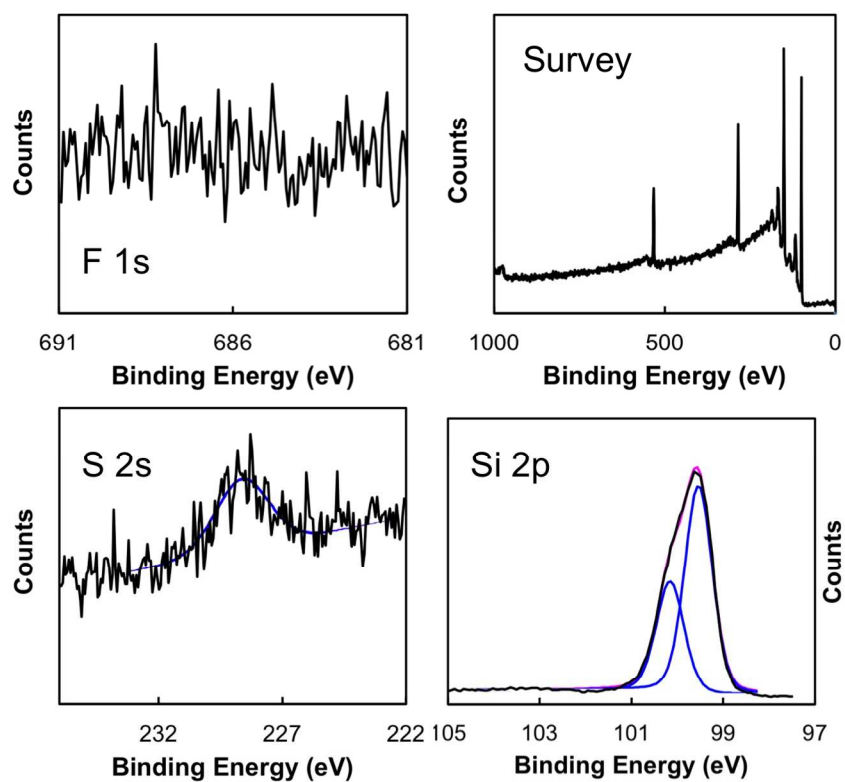
**Figure SA2.** C 1s (15 scans), Si 2p (20 scans), S 2s (30 scans), and survey (2 scans) XP spectra of a mixed  $\text{CH}_3/\text{SC}_4\text{H}_3$ -Si(111) with  $\theta_{\text{SC}_4\text{H}_3} \approx 0.35$ .



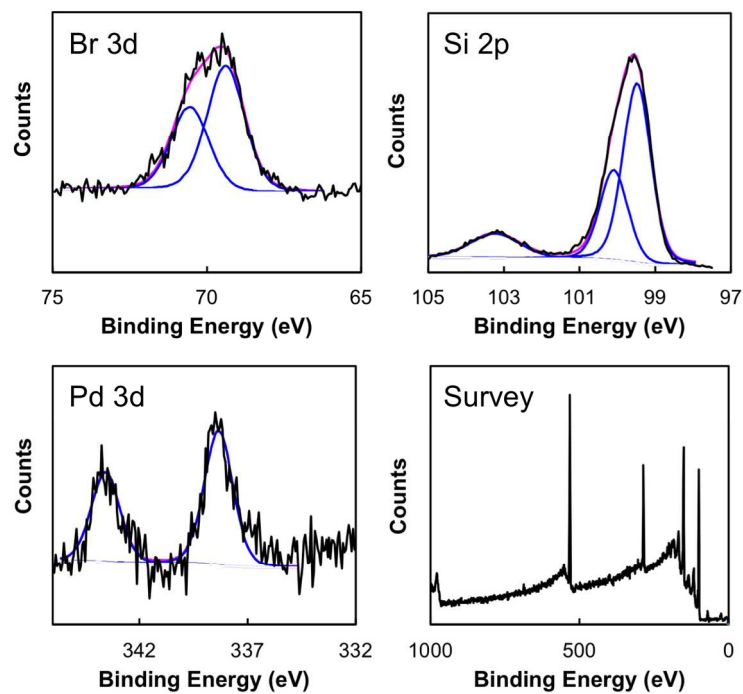
**Figure SA3.** Br 3d (50 scans), Si 2p (30 scans), S 2s (60 scans), and survey (4 scans) XP spectra of a mixed  $\text{CH}_3/\text{SC}_4\text{H}_2\text{Br-Si(111)}$  with  $\theta_{\text{SC}_4\text{H}_3} \approx 0.25$ ,  $\theta_{\text{Br-SC}_4\text{H}_2} = 0.16$ , and  $\theta_{\text{Br-Si}} = 0.05$ .



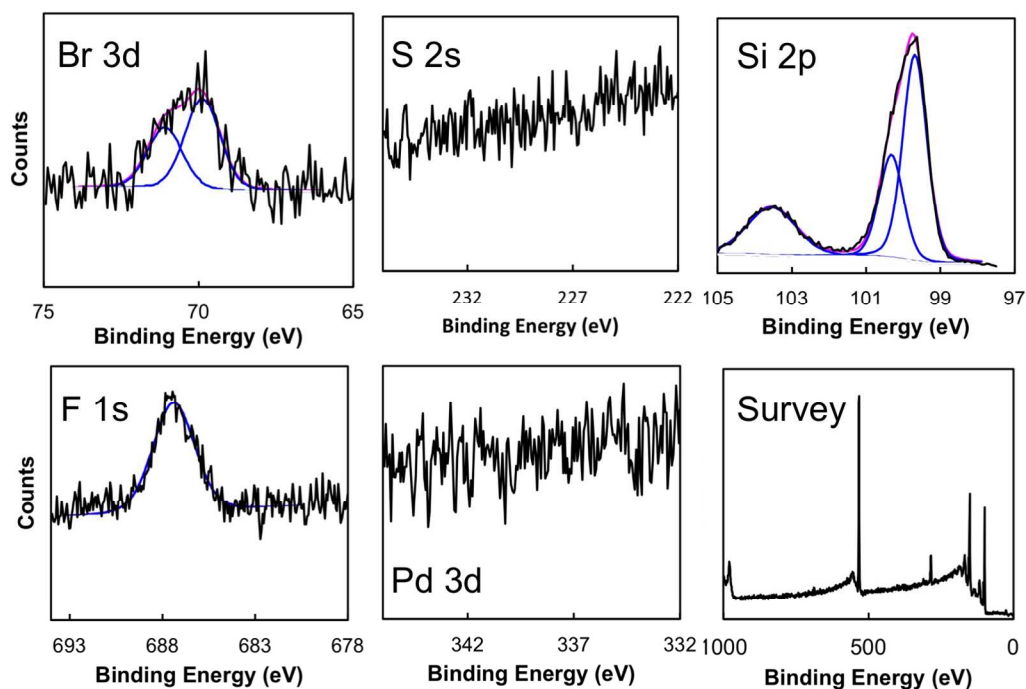
**Figure SA4.** Br 3d (100 scans), F 1s (120 scans), Pd 3d (120 scans), Si 2p (33 scans), S 2s (30 scans), and survey (2 scans) XPS spectra of a mixed CH<sub>3</sub>/FSty-SC<sub>4</sub>H<sub>2</sub>-Si(111) with  $\theta_{\text{SC}_4\text{H}_3} \approx 0.20$  and  $\theta_{\text{FSty}} = 0.11$ .



**Figure SA5.** F 1s (150 scans), S 2s (200 scans), Si 2p (70 scans), and survey (4 scans) XP spectra of CH<sub>3</sub>/SC<sub>4</sub>H<sub>3</sub>-Si(111) after exposure to Pd(PPh<sub>3</sub>)<sub>4</sub> (toluene, RT), then 4-fluorostyrene (DMF, 100 °C), but with no exposure to NBS. No F was detected using XPS.

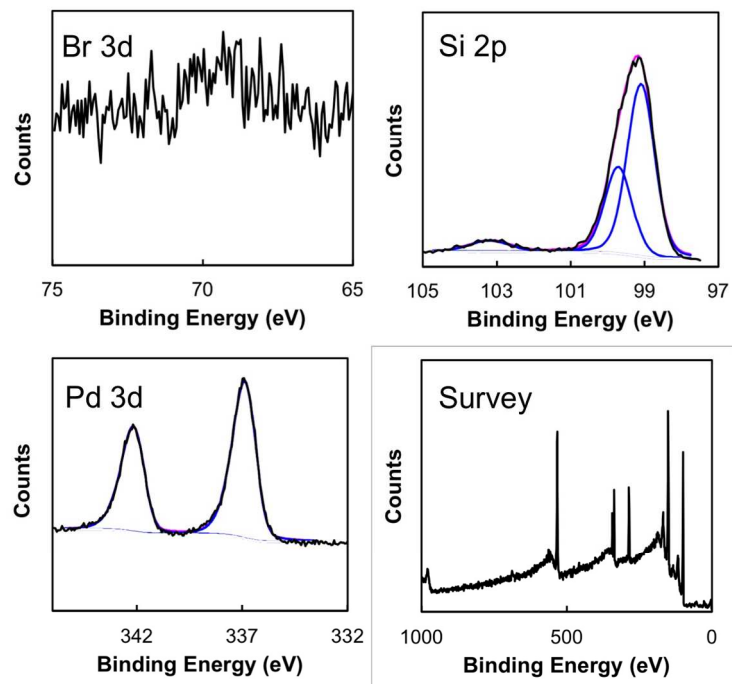


**Figure SA6.** Br 3d (250 scans), Pd 3d (250 scans), Si 2p (70 scans), and survey (40 scans) XP spectra of a Br-Si(111) surface after exposure to Pd(PPh<sub>3</sub>)<sub>4</sub> (toluene, RT).  $\theta_{\text{Pd}} = 0.06$ .

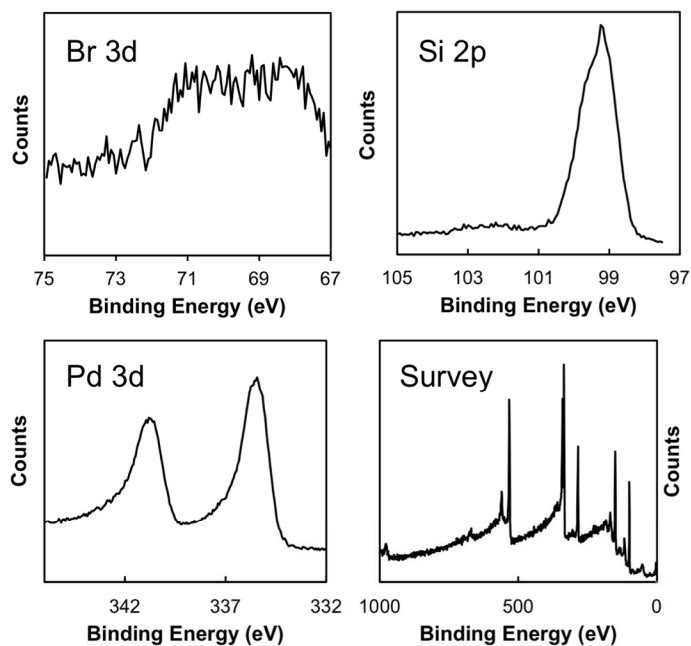


**Figures SA7.** S 2s (150 scans), Br 3d (200 scans), Pd 3d (200 scans), F 1s (100 scans), Si 2p (20 scans), and survey (4 scans) XP spectra of Pd activated Br-Si(111) after reaction with 4-fluorostyrene (DMF, 100 °C). Pd catalyzed hydrosilylation takes place under these conditions.

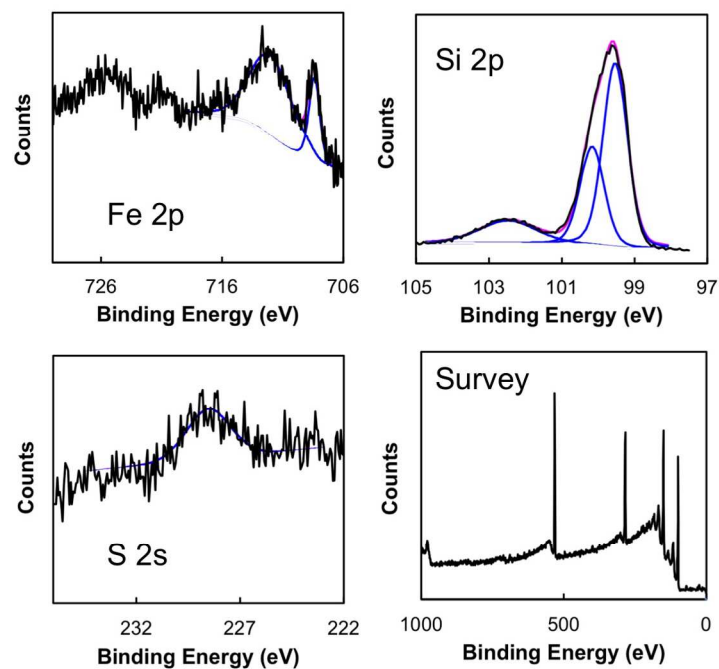




**Figure SA8.** Br 3d (250 scans), Pd (250 scans), Si (70 scans), and survey (4 scans) spectra of H-Si(111) after exposure to Pd(PPh<sub>3</sub>)<sub>4</sub> (toluene, RT).

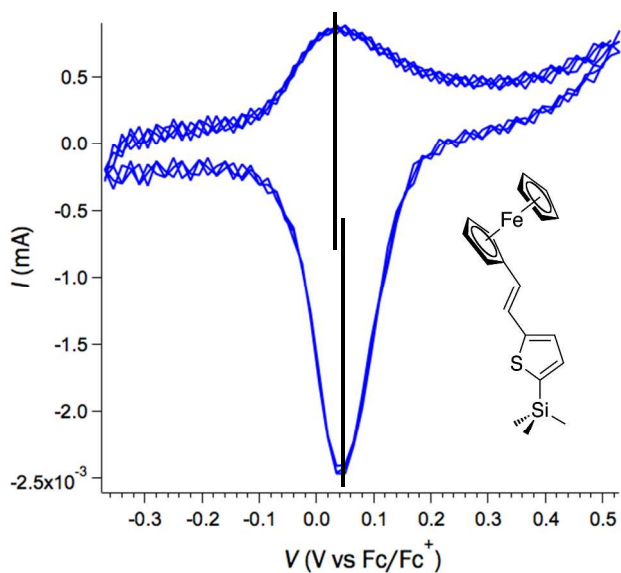


**Figure SA9.** Br 3d (150 scans), Si 2p (40 scans), Pd 3d (100 scans), and survey (4 scans) spectra of  $\text{CH}_3/\text{SC}_4\text{H}_2\text{Br-Si(111)}$  surfaces after exposure to  $\text{Pd(dba)}_2$  (toluene, RT).



**Figures SA10.** Fe (200 scans) XPS spectrum of the CH<sub>3</sub>/Fc-SC<sub>4</sub>H<sub>2</sub>-Si(111) surface after cyclic voltammetry experiments.  $\theta_{\text{Fe}} = 0.082$ , and  $\theta_{\text{SC}_4\text{H}_3} + \theta_{\text{SC}_4\text{H}_2\text{-Fc}} = 0.24$ .

## B. Cyclic Voltammetry



**Figure SB1.** Cyclic voltammogram of vinyl ferrocene modified n-Si,  $\theta_{Fc} = 0.12$ . 1.0 M  $LiClO_4$  in acetonitrile,  $2500 \text{ mV s}^{-1}$ . The asymmetry is due to the electron transfer dynamics at non-degenerately doped semiconductor electrodes. The small splitting, 0.01 V, between the potentials where the cathodic and anodic currents exhibited peaks suggests facile electron transfer through the conjugated linker.

### C. Substrate overlayer model

The substrate overlayer model can be used here, as described in the text:

$$d_{ov} = \ln \left[ \left( \frac{I_{ov}}{I_{Si}} \right) \left( \frac{SF_{Si}}{SF_{ov}} \right) \left( \frac{\rho_{Si}}{\rho_{ov}} \right) + 1 \right] \lambda \sin(\theta)$$

$d_{ov}$  is the thickness of the overlayer,  $I_{ov}$  and  $I_{Si}$  are the signal intensity of the  $C_{Si}$  and  $Si_{bulk}$  2p(3/2) XPS signals respectively.  $SF_{ov}$  and  $SF_{Si}$  are the modified sensitivity factors for the Si 2p(3/2) and C 1s signals.  $\rho_{ov}$  (0.14 mol cm<sup>-3</sup> based on  $d_{CH3}$ ) and  $\rho_{Si}$  (0.083 mol cm<sup>-3</sup> based on Si crystal structure) are the atomic density of C in the overlayer and in the Si crystal.  $\lambda$  is the mean free path of electrons, determined empirically as 3.5 nm for Si 2p electrons, {haber; laibinis 1991; tufts 1992} and  $\theta$  is the angle from the horizontal to the detector (35°).

$$SF_x = SF_{scf} \left[ \frac{1486 - BE}{1486 - 284} \right]^{S_{exp}}$$

Modified sensitivity factors are calculated based on the binding energy of the electron (BE), and the configuration dependent sensitivity exponent ( $S_{exp}$ ). In this case,  $S_{exp} = 0.6$  and  $SF_{Si} = 0.9$  for the 2p electrons.

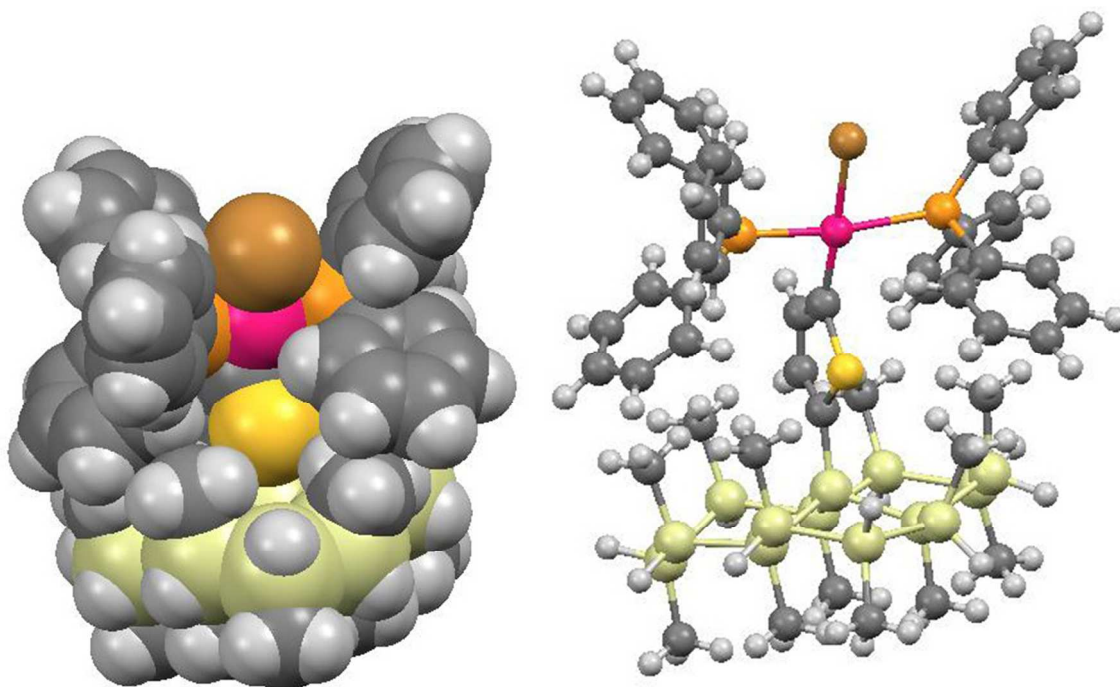
$d_{ov} = 0.097$  for the  $CH_3-Si(111)$  surface.  $d_o$  for a methyl group is 0.234 nm, and thus gives 0.41 ML  $CH_3$  groups. 1 monolayer of  $CH_3$  groups having a density of  $1.89 \times 10^{15}$  (based on  $d_{CH3} = 2.3$  Å), gives  $\Gamma_{CH3} 8.0 \times 10^{14}$  cm<sup>-2</sup> or  $\theta_{CH3-Si} = 0.99 \pm 0.06$  (based on  $\Gamma_{Si(111)} = 7.83 \times 10^{14}$  cm<sup>-2</sup>).

Similarly, the fractional overlayer equation

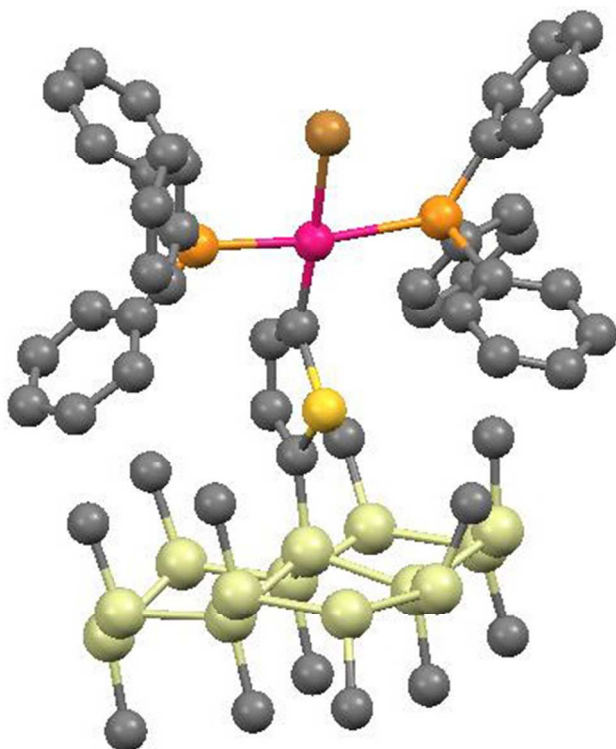
$$\Phi_{ov} = \left[ \frac{\lambda \sin \theta}{a_{ov}} \right] \left( \frac{SF_{Si}}{SF_{ov}} \right) \left( \frac{\rho_{Si}}{\rho_{ov}} \right) \left( \frac{I_{ov}}{I_{Si}} \right)$$

gives a similar value of  $\Phi_{ov} = 0.43$  or  $\theta_{CH3-Si} = 1.04 \pm 0.06$ .

## D. Molecular Modelling of Surface Species



**Figure SD1.** Geometry optimized molecular model of the proposed Pd-activated species, namely  $\text{CH}_3/\text{Br-Pd(PPh}_3)_2\text{-SC}_4\text{H}_2\text{-Si(111)}$ , on a small portion of hexagonal Si(111) surface: (left) space-filling model of the species, (middle) ball-and-stick model of the same species, (right) ball-and-stick model of the species with H's omitted for clarity. The overall 'planar' rigidity of the Si(111) framework was in this case was enforced by substituting methyl groups in the basal plane. The Pd-ligated surface was modeled using the 3-21G basis set and the functional PW91.<sup>1</sup> The geometries were optimized to a low root mean square gradient ( $\text{GRMS} < 0.001$ ) in Firefly,<sup>2</sup> and the resulting models were visualized in Mercury.<sup>3</sup>



**Figure SD2.** Geometry optimized molecular model of the proposed Pd-activated species, namely  $\text{CH}_3/\text{Br-Pd}(\text{PPh}_3)_2\text{-SC}_4\text{H}_2\text{-Si}(111)$ , on a small portion of hexagonal  $\text{Si}(111)$  surface: (above) ball-and-stick model of the species with H's omitted for clarity. The overall 'planar' rigidity of the  $\text{Si}(111)$  framework in this case was enforced by substituting methyl groups in the basal plane. The Pd-ligated surface was modeled using the 3-21G basis set and the functional PW91.<sup>1</sup> The geometries were optimized to a low root mean square gradient ( $\text{GRMS} < 0.001$ ) in Firefly,<sup>2</sup> and the resulting models were visualized in Mercury.<sup>3</sup>

## References

- (1) (a) Perdew, J. P.; Chevary, J. A.; Vosko, S. H.; Jackson, K. A.; Pederson, M. R.; Singh, D. J.; Fiolhais, C. *Phys. Rev. B: Condens. Matter* **1993**, *48*, 4978. (b) Perdew, J. P.; Chevary, J. A.; Vosko, S. H.; Jackson, K. A.; Pederson, M. R.; Singh, D. J.; Fiolhais, C. *Phys. Rev. B: Condens. Matter* **1992**, *46*, 6671–6687.
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